Attorney Docket No. ANO6129P1US
Serial No. 10/007,861
PEGEIVED
CENTRAL FAX GENTER

LISTING OF THE CLAIMS

JUL 2 6 2006

- 1. (Currently Amended) A process for the production of an aqueous sol containing silica-based particles which comprises the sequential steps of:
- (a) acidifying an aqueous silicate solution to a pH of from 1 to 4 to form an acid sol;
- (b) alkalising in a first alkalisation step the acid sol, while keeping at an SiO₂ content within the range of from 4.5 to 8% by weight, to form an alkalised sol having a pH of at least 7;
- (c) allowing particle growth of the alkalised sol for at least 10 minutes; and
- (d) alkalizing in a second alkalization step the obtained sol to a pH of at least 10.0 by adding alkali selected from the group consisting of lithium hydroxide, sodium hydroxide or potassium hydroxide; an aqueous silicate solution, or a mixture thereof.

2 - 25. Cancelled.

- 26. (Previously Presented) The process according to claim 1, wherein the process further comprises:
- (e) concentrating the alkalised sol obtained according to (b).
- 27. (Previously Presented) The process according to claim 1, wherein the process further comprises:
- (e) concentrating the alkalised sol subjected to particle growth obtained according to (c).
- 28. (Previously Presented) The process according to claim 1, wherein the process further comprises:
- (e) concentrating the alkalised sol obtained according to (d).

HINANGYANGS129P1USYANGS128P1U9.7HS9.RimphoGA of 02.27,09,40c

- 29. (Previously Presented) The process according to claim 1, wherein the aqueous sol obtained in the process has a specific surface area of at least 90 m²/g aqueous sol.
- 30. (Previously Presented) The process according to claim 26, wherein the aqueous sol obtained in the process has a specific surface area of at least 95 m^2/g aqueous sol.
- 31. (Previously Presented) The process according to claim 1, wherein the alkalisation according to (b) and (d) is carried out by means of an aqueous silicate solution.
- 32. (Previously Presented) The process according to claim 1, wherein the particle growth according to (c) is carried out at a temperature within the range of from 35 to 95°C.
- 33. (Previously Presented) The process according to claim 1, wherein the alkalisation according to (d) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 15:1 to 30:1 and a pH of at least 10.6.
- 34. (Previously Presented) The process according to claim 1, wherein the process further comprises addition of an aluminium-containing compound, a boron-containing compound or a mixture thereof.
- 35. (Previously Presented) The process according to claim 1, wherein the silica-based particles obtained in the process have a specific surface area of at least 550 m²/g SiO₂.
- 36. (Withdrawn) An aqueous sol containing silica-based particles obtained by a process which comprises:

AKZO PATENT

- (a) acidifying an aqueous silicate solution to a pH of from 1 to 4 to form an acid sol:
- (b) alkalising the acid sol at an SiO₂ content within the range of from 4.5 to 8% by weight to form an alkalised sol having a pH of at least 7;
- (c) allowing particle growth of the alkalised sol for at least 10 minutes; and
- (d) alkalising the obtained sol to a pH of at least 10.0.
- 37. (Withdrawn) The aqueous sol according to claim 36, wherein the process further comprises:
- (e) concentrating the sol obtained according to (c).
- 38. (Withdrawn) The aqueous sol according to claim 36, wherein the process further comprises:
- (e) concentrating the sol obtained according to (d).
- 39. (Withdrawn) The aqueous sol according to claim 37, wherein it has a specific surface area of at least 95 m²/g aqueous sol.
- 40. (Withdrawn) The aqueous sol according to claim 36, wherein the aqueous sol has a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 15:1 to 30:1 and a pH of at least 10.6.
- 41. (Withdrawn) The aqueous sol according to claim 36, wherein the sol comprises an aluminum-containing compound, a boron-containing compound or a mixture thereof.
- 42. (Withdrawn) The aqueous sol according to claim 36, wherein the silicabased particles have a specific surface area of at least 550 m²/g SiO₂.
- 43. (Currently Amended) A process for the production of an aqueous sol containing silica-based particles which comprises the sequential steps of:

- (a) acidifying an aqueous silicate solution to a pH of from 1 to 4 to form an acid sol;
- (b) alkalising in a first alkalisation step the acid sol, while keeping at an SiO₂ content within the range of from 4.5 to 8% by weight, to form an alkalised sol;
- (c) heat-treating the alkalised sol at a temperature of at least 30°C; and
- (d) alkalising in a second alkalization step the heat-treated sol to a pH of at least 10.0 by adding alkali selected from the group consisting of lithium hydroxide, sodium hydroxide, or potassium hydroxide; an aqueous silicate solution, or a mixture thereof.
- 44. (Previously Presented) The process according to claim 43, wherein the process further comprises:
- (e) concentrating the alkalised sol obtained according to step (b).
- 45. (Previously Presented) The process according to claim 43, wherein the process further comprises:
- (e) concentrating the alkalised sol obtained according to step (c).
- 46. (Previously Presented) The process according to claim 43, wherein the process further comprises:
- (e) concentrating the alkalised sol obtained according to step (d).
- 47. (Previously Presented) The process according to claim 43, wherein the aqueous sol obtained in the process has a specific surface area of at least 90 m²/g aqueous sol.
- 48. (Previously Presented) The process according to claim 43, wherein the aqueous sol obtained in the process has a specific surface area of at least 95 m^2/g aqueous sol.

- 49. (Previously Presented) The process according to claim 43, wherein the alkalisation according to (b) and (d) is carried out by means of an aqueous silicate solution.
- 50. (Previously Presented) The process according to claim 43, wherein the heat-treatment according to (c) is carried out for 20 to 240 minutes.
- 51. (Previously Presented) The process according to claim 43, wherein the alkalisation according to (d) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 15:1 to 30:1 and a pH of at least 10.6.
- 52. (Previously Presented) The process according to claim 43, wherein the process further comprises addition of an aluminum-containing compound, a boron-containing compound or a mixture thereof.
- 53. (Previously Presented) The process according to claim 43, wherein the silica-based particles obtained in the process have a specific surface area of at least 550 m²/g SiO₂.
- 54. (Withdrawn) An aqueous sol containing silica-based particles obtained by a process comprising:
- (a) acidifying an aqueous silicate solution to a pH of from 1 to 4 to form an acid sol:
- (b) alkalising the acid sol at an SiO_2 content within the range of from 4.5 to 8% by weight to form an alkalised sol;
- (c) heat-treating the alkalised sol at a temperature of at least 30°C; and
- (d) alkalising the heat-treated sol to a pH of at least 10.0.
- 55. (Withdrawn) The aqueous sol according to claim 54, wherein the process further comprises:
- (e) concentrating the sol obtained according to (c).

- 56. (Withdrawn) The aqueous sol according to claim 54, wherein the process further comprises:
- (e) concentrating the sol obtained according to (d).
- 57. (Withdrawn) The aqueous sol according to claim 54, wherein it has a specific surface area of at least 95 m²/g aqueous sol.
- 58. (Withdrawn) The aqueous sol according to claim 54, wherein it has a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonlum, within the range of from 15:1 to 30:1 and a pH of at least 10.6.
- 59. (Withdrawn) The aqueous sol according to claim 54, wherein it comprises an aluminum-containing compound, a boron-containing compound or a mixture thereof.
- 60. (Withdrawn) The aqueous sol according to claim 54, wherein the silicabased particles have a specific surface area of at least 550 m²/g SiO₂.
- 61. (Currently Amended) A process for the production of an aqueous sol containing silica-based particles which comprises:
- (a) acidifying an aqueous silicate solution to a pH of from 1 to 4 to form an acid sol;
- (b) alkalising in a first alkalisation step the acid sol, while keeping at an SiO₂ content within the range of from 4.5 to 8% by weight, to form an alkalised sol;
- (c) heat-treating the alkalised sol obtained according to (b) at a temperature within the range of from 35 to 95°C for 20 to 240 minutes;
- (d) alkalizing in a second alkalization step the heat-treated sol obtained according to (c) to a pH of at least 10.0 and a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 15:1 to 30:1 by adding alkali, an aqueous silicate solution, or a mixture thereof;
- (e) concentrating the sol obtained according to (c) or (d); and

- (f) providing an aqueous sol which has a specific surface area of at least 95 m²/g aqueous sol and contains silica-based particles which have a specific surface area of at least 550 m²/g SiO₂.
- 62. (Previously Presented) The process according to claim 61, wherein the alkalisation according to step (b) and step (d) is carried out by means of an aqueous silicate solution.
- 63. (Previously Presented) The process according to claim 61, wherein the alkalisation according to (d) produces a pH of at least 10.6.
- 64. (Withdrawn) An aqueous sol containing silica-based particles obtained by a process which comprises:
- (a) acidifying an aqueous silicate solution to a pH of from 1 to 4 to form an acid sol:
- (b) alkalising the acid sol at an SiO₂ content within the range of from 4.5 to 8% by weight to form an alkalised sol;
- (c) heat-treating the alkalised sol at a temperature within the range of from 35 to 95°C for 20 to 240 minutes;
- (d) alkalising the heat-treated sol to a pH of at least 10.0 and a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 15:1 to 30:1;
- (e) concentrating the sol obtained according to step (c) or step (d); and
- (f) providing an aqueous sol which has a specific surface area of at least 95 m²/g aqueous sol and contains silica-based particles which have a specific surface area of at least 550 m²/g SiO₂.
- 65. (Withdrawn) The aqueous sol according to claim 64, wherein it has a pH of at least 10.6.

66 - 72. (Cancelled)

- 73. (New) The process according to claim 1, wherein said SiO₂ content is kept within the range of from 5.0 to 7.5% by weight in step (b).
- 74. (New) The process according to claim 73, wherein the alkalization according to (d) produces a sol having an S-value within the range of 20 to 40%.
- 75. (New) The process according to claim 1, wherein the alkalization according to (b) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 20:1 to 80:1.
- 76. (New) The process according to claim 75, wherein the alkalization according to (b) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 30:1 to 70:1.
- 77. (New) The process according to claim 76, wherein the alkalization according to (d) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 12:1 to 40:1.
- 78. (New) The process according to claim 77, wherein the alkalization according to (d) produces a sol having a molar ratio of SiO₂ to M₂O, where M is alkali metal or ammonium, within the range of from 15:1 to 30:1.
- 79. (New) The process according to claim 78, wherein the alkalization according to (d) produces a sol having an S-value within the range of 10 to 45%.
- 80. (New) The process according to claim 43, wherein said SiO₂ content is kept within the range of from 5.0 to 7.5% by weight in step (b).
- 81. (New) The process according to claim 80, wherein the alkalization according to (d) produces a sol having an S-value within the range of 20 to 40%.

- 82. (New) The process according to claim 43, wherein the alkalization according to (b) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 20:1 to 80:1.
- 83. (New) The process according to claim 82, wherein the alkalization according to (b) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 30:1 to 70:1.
- 84. (New) The process according to claim 83, wherein the alkalization according to (d) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 12:1 to 40:1.
- 85. (New) The process according to claim 84, wherein the alkalization according to (d) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 15:1 to 30:1.
- 86. (New) The process according to claim 85, wherein the alkalization according to (d) produces a sol having an S-value within the range of 10 to 45%.
- 87. (New) The process according to claim 61, wherein said SiO₂ content is kept within the range of from 5.0 to 7.5% by weight in step (b).
- 88. (New) The process according to claim 87, wherein the alkalization according to (d) produces a sol having an S-value within the range of 20 to 40%.
- 89. (New) The process according to claim 61, wherein the alkalization according to (b) produces a sol having a molar ratio of SiO₂ to M₂O, where M is alkali metal or ammonium, within the range of from 20:1 to 80:1.
- 90. (New) The process according to claim 89, wherein the alkalization according to (b) produces a sol having a molar ratio of SiO_2 to M_2O , where M is alkali metal or ammonium, within the range of from 30:1 to 70:1.

Jul 26 2006 15:24

P.14

Attorney Docket No. ANO6129P1US Serial No. 10/007,861

91. (New) The process according to claim 90, wherein the alkalization according to (d) produces a sol having an S-value within the range of 10 to 45%.

P://morran/ANC/ANO0129P1UE/ANO0189P1UE.\$159.Roman/OA of 02,27,08.doc